Call for Papers

7th ITG International Vacuum Electronics Workshop (IVEW) 2020 and

13th International Vacuum Electron Sources Conference (IVeSC) 2020

May 26 - 29, 2020 Physikzentrum Bad Honnef (PBH), Bad Honnef, Germany (www.pbh.de)

organized by ITG-Fachausschuss MN 6 "Vacuum Electronics and Displays" and the European Steering Committee of IVeSC



Information Technology Society (ITG) within VDE

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Topics of the Conference

New developments and applications of vacuum electronic devices as well as materials, technologies and manufacturing techniques such as:

- Electron Emission Phenomena and Modelling
- Vacuum Electronic and Discharge Devices and their Applications
- Technologies and Production Processes in Vacuum Electronics

SCHEDULE

Deadline for Submission of Abstracts Notification of Acceptance Deadline for Registration and Payment Submission of Presentations in .pdf format for the Electronic Proceedings February 29, 2020 March 20, 2020 April 24, 2020

May 26, 2020

Files (abstracts and presentations) shall be sent electronically. See abstract template (sample paper abstract) on Web Site.

The latest information on the conference and the final program can be found at the Web Site http://www.ihe.kit.edu/kooperationen itg.php

Submitted papers should include but are not limited to the following areas of interest:

Electron Emission Phenomena and Modelling

- Thermionic and field emission
- Secondary electron emission
- Photoelectric and ferroelectric emission
- Emission from carbon
- Wide bandgap materials

- ♦ NEA/LEA materials
- Hollow cathodes for ion thrusters
- Gas discharge electrodes (lamps & lighting triple oxides, thoriated tungsten alternatives, electric propulsion,)

Vacuum Electronic and Discharge Devices and their Applications

- Microwave Tubes (TWTs, Klystrons, Fast-Wave Devices ...)
- Grid Controlled Tubes
- Vacuum Microelectronic and Nanoelectronic Devices
- Picture Tubes and Image Intensifiers
- X-Ray Tubes

- Pseudospark Devices
- ♦ Vacuum Arc Ion Sources
- High Current Diodes
- Pulsed Power Switching
- Gas Lasers and Gas Discharge Tubes
- Electric Space Propulsion
- Vacuum Interrupters and Spark Gaps

Technologies and Production Processes in Vacuum Electronics

- Laser-, Electron-Beam-, Ion-Beam- and Plasma Processing Systems
- Surface Analytics, Treatment, Evacuation and Getters
- Interconnection and Assembly Techniques
- Vacuum-Microelectronics and Vacuum-Nanoelectronics Technologies
- Cathode (production) technologies, materials and characterization

The paper should be suitable for **20 minutes of oral presentation.** Poster presentations are welcome. The conference language is **English**.

One-page abstracts should be submitted as .pdf-file electronically to Dr. W. Knapp, to Prof. Dr. M. Thumm and to Dr. J. M. Roquais giving a preference for IVEW or IVeSC, not later than Feb. 29, 2020.

Please indicate if you prefer a poster presentation.

IVEW Chairman:	IVEW Vice Chairman:	IVeSC Chairman:
DrIng. Wolfram Knapp	Prof. Dr. Dr. h.c. Manfred Thumm	DrIng. Jean-Michel Roquais
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